

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/807298	D	430	270.1	355	CLARK

APPLICANTS: Frank Schadt III, Michael Fryd, Mookan Periyasamy  
 TITLE: Photoresists and processes for microlithography

PTO-2040 (12/95)

INTERNATIONAL CLASSIFICATION		CLASS		SUBCLASS	

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